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Application Data Sheet 37 CFR 1.			CED 1	76 Attorne	Attorney Docket Number FIS920030342US1					
			OI IC I	Application Number						
Title of Inv	Title of Invention Method of Forming Thin SGOI Waters with High Relaxation and Low Stacking Fault Defect Density									
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Mailing A	ddress of A	pplicant:								
Address 1	l	29 Lilac	Lane							
Address 2										
City	Danbury				Sta	te/Provir	nce	CT		
Postal Co	de	06810			Country	US				
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Applicant	Authority (	nventor	CLegal	Representativ	e under 35	U.S.C. 11	7	OParty of In	terest under 35 U.S.	C. 118
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Mailing A	Mailing Address of Applicant:									
Address 1	Address 1 32 Nicole Drive									
Address 2	!									
City	City Wappingers Falls State/Province NY									
Postal Code 12590					Country	US				
Applicant	3								Remove	
	Applicant Authority ⊕Inventor									

Middle Name

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State/Province

Family Name

Non US Residency Active US Military Service

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Suffix

Prefix Given Name

Devendra

Pleasantville

Residence Information (Select One) ( US Residency

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Method of Forming Thin SGOI Waters with High Relaxation and Low Stacking Fault Defect Density

Application Number

Application Data Sheet 37 CFR 1.76

Title of Invention

FIS920030342US1

Citizenship under 37 CF	R 1.41(b) i	US	i							
Mailing Address of Applicant:										
Address 1 90 Sky Top Drive										
Address 2	Address 2									
City Pleasantville State/Province NY										
Postal Code	10570			Cou	intryi	US				
Applicant 4									Remove	
Applicant Authority (1)	ventor OL	egal f	Representativ	ve unde	er 35 t	J.S.C. 11	S.C. 117 Party of Interest under 35 U.S.C. 118			
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Mailing Address of Appl										
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Application Inform	ation:									
Title of the Invention	Method of	Formi	ing Thin SGC	N Wafe	ers with	High Rel	laxation a	and Low Sta	cking Fault Defect (	Density
Attorney Docket Number	IS1		Small Entity Status Claimed							
Application Type Nonprovisional										
Subject Matter										
Suggested Class (if any)					S	ub Class	s (if any	()		
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Application Data Sheet 37 CFR 1.76			Attorney Docket Number	FIS920030342US1				
			Application Number					
Title of Invention Method of Forming Thin SGOI Walfers with High Relaxation and Low Stacking Fault Defect Density								
Publication Information:								
Request Early Publication (Fee required at time of Request 37 CFR 1.219)								
Request Not to Publish. I hereby request that the attached application not be published under 35 U.S.C. 122(b) and certify that the invention disclosed in the state-ded application has not been and will not be the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing.								

### Representative Information:

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Please Select One:	Customer Number	US Patent Practitioner	US Representative (37 CFR 11.9)
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This section allows for the applicant to claim benefit under 35 U.S.C. 119(e), 120, 121, or 365(c). Providing this information in the application data sheet constitutes the specific reference required by 35 U.S.C. 119(e) or 120, and 37 CFR 1.78(a)(2) or CFR 1.78(a) (4) and need not otherwise he made part of the specification

(1) And the second seco							
Prior Application Status	Pending		Remove				
Application Number	Continuity Type	Prior Application Number	Filing Date (YYYY-MM-DD)				
PCT/US2004/001555	a 371 of international		2004-01-16				

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This section allows for the applicant to claim benefit of foreign priority and to identify any prior foreign application for which priority is not claimed. Providing this information in the application data sheet constitutes the claim for priority as required by 35 U.S.C. 119(b). and 37 CFR 1.55(a).

		100	SHOVE
Application Number	Country i	Parent Filing Date (YYYY-MM-DD)	Priority Claimed
			Yes ○ No
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#### Assignee Information:

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Assignee 1

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Application Da	ta Sheet 37 CFR 1.76	Attorney Docket Number	FIS920030342US1	
Аррисацоп Ба	ta Sileet 37 CFK 1.76	Application Number		
Title of Invention	Method of Forming Thin SGC	I Wafers with High Relaxation a	and Low Stacking Fault Defect Density	
Organization Name	International Business M	lachines Corporation		
Mailing Address I	nformation:			
Address 1	New Orchard Road			
Address 2				
City	Armonk	State/Provi	nce NY	
Country i US		Postal Code	10504	
Phone Number		Fax Number		
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#### Signature:

A signature of the applicant or representative is required in accordance with 37 CFR 1.33 and 10.18. Please see 37 CFR 1.4(d) for the form of the signature.								
Signature	/Yuanmin Cai /		Date (YYYY-MM-DD)	2006-07-10				
First Name	Yuanmin	Last Name	Cai	Registration Number	56513			

This collection of information is required by 37 CFR 1.76. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 23 minutes to complete, including gathering, preparing, and submitting the completed application data sheet form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450, DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

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